

Docket No.: 241675US0

**OBLON** SPIVAK **McClelland** MAIER NEUSTADT P.C.

ATTORNEYS AT LAW

NORMAN F. OBLON (703) 413-3000 NOBLON@OBLON.COM

JAMES J. KELLY, PH.D. (703) 413-3000 JKELLY@OBLON.COM

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

RE: Application Serial No.: 10/642,694

Igor ROZHANSKII, et al. Applicants:

Filing Date: August 19, 2003

For: NOVEL AROMATIC SULFONIC ACID ESTER DERIVATIVE, POLYARYLENE, POLYARYLENE HAVING SULFONIC ACID GROUP AND PROCESS FOR PRODUCING THE SAME, AND POLYMER SOLID ELECTROLYTE AND PROTON-

CONDUCTIVE MEMBRANE

Group Art Unit: 1711 Examiner: D. TRUONG

SIR:

Attached hereto for filing are the following papers:

## REQUEST FOR RECONSIDERATION

Our check in the amount of \$0.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C. Norman F. Oblon

Customer Number

(703) 413-3000 (phone) (703) 413-2220 (fax)

James J. Kelly, Ph.D. Registration No. 41.504



## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

:

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: EXAMINER: D. TRUONG

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SIR:

Responsive to the Office Action dated January 17, 2006, Applicants respectfully request reconsideration of the above-identified application in view of the following amendments and remarks:

Remarks begin on page 2 of this paper.